FORM 1449*

INFORMATION DISCLOSURE STATEMENT

IN AN APPLICATION

(Use several sheets if necessary)



Docket Number: Application Number: 10873.784USWO 09/936,601

Applicant: YAMADA et al.

Filing Date: September 14, 2001

Group Art Unit: Unknown

			U.S. PATENT DOCUMENTS					
EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE		
UF	5,194,363	March 1993	Yoshioka et al.	_				
1	5,254,832	Oct. 1993	Gartner et al.				·	
V	4,670,345	June 1987	Morimoto et al.					
		FC	PREIGN PATENT DOCUMEN	ITS		•		
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION		
						YES	NO	
18	4-10979	Jan. 1992	Japan	-		See IDS		
	7-214913	Aug. 1995	Japan			Abstract		
	387 898	Sept. 1990	EPO					
	5-229258	Sept 1993	Japan			Abstract		
	4-69282	March 1992	Japan			Abstract		
	3-42276	Feb. 1991	Japan	-		Abstract		
	1-277338	Nov. 1989	Japan			Abstract		
	898 273	Feb. 1999	EPO					
	3-76684	April 1991	Japan			Abstract		
	6-171234	June 1994	Japan			Abstract		
V	874 361	Oct. 1998	EPO					
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UF.	"High Spec 26 (1987),	"High Speed Overwritable Phase Change Optical Disk Material"; Yamada, N. et al.; Japanése Jounal of Applied Physics, Vol. 26 (1987), Supplement 26-4, page 61-66						
	"Nitrogen Vol.37(19	Doping Effect (998), Part 1, No.	Phase Change Optical Disks", Kojima R. et al., Japanese Journal of Applied Physics, page 2098-2103					
	"Rapid-pl N. et al.,	"Rapid-phase transitions of GeTe-Sb ₂ pseudobinary amorphous thin films for an optical disk memory", Yamada, N. et al., Journal of Applied Physics, Vol. 69 (1991), No. 5, page 2849-2856						
	"Erasable	"Erasable Phase-Change Optical Materials", Yamada, N., MRS Bulletin Vol.21(1996), No.9, page 48-50						
	"Crystal s	"Crystal structure of Ge-Sb-Te meta-stable phase", Nonaka, T. et al., Proceedings of the 10th Symposium on Phase-Change Recording, Nov. 26-27, 1998, Shizuoka, Japan, page 63-66						

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citat and not considered. Include copy of this form for next communication to the Applicant.

